

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/750,023	12/31/2003	Ho Lee	AB-1350 US	9344
32605	7590 10/16/2006		EXAMINER	
MACPHERSON KWOK CHEN & HEID LLP 2033 GATEWAY PLACE			LUND, JEFFRIE ROBERT	
SUITE 400	WAITLACE		ART UNIT PAPER NUMBER	
SAN JOSE,	CA 95110		1763	
			DATE MAILED: 10/16/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

				(
		Application No.	Applicant(s)				
Office Action Summary		10/750,023	LEE, HO	,			
		Examiner	Art Unit				
		Jeffrie R. Lund	1763				
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet with the o	orrespondence ad	dress			
WHIC - Exter after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DANSIONS of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. Depriod for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	N. nely filed the mailing date of this cc D (35 U.S.C. § 133).				
Status							
1)⊠	Responsive to communication(s) filed on 7/24/	06.					
2a)⊠	This action is FINAL . 2b) This action is non-final.						
3)□	☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Dispositi	on of Claims						
4)⊠	Claim(s) 1-12 is/are pending in the application.						
	4a) Of the above claim(s) is/are withdrawn from consideration.						
5)	5) Claim(s) is/are allowed.						
6)⊠	Claim(s) <u>1-12</u> is/are rejected.	•					
7)	Claim(s) is/are objected to.						
8)□	Claim(s) are subject to restriction and/or	r election requirement.					
Applicati	on Papers	•					
9)□	The specification is objected to by the Examine	r.					
10)⊠ The drawing(s) filed on <u>31 December 2003</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.							
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11)[The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PT	O-152.			
Priority u	ınder 35 U.S.C. § 119						
_	12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of:						
	1. Certified copies of the priority documents have been received.						
	2. Certified copies of the priority documents have been received in Application No						
	3. Copies of the certified copies of the priority documents have been received in this National Stage						
	application from the International Bureau (PCT Rule 17.2(a)).						
* S	see the attached detailed Office action for a list of	of the certified copies not receive	d.				
			•				
Attachmen							
	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948)	4) Interview Summary					
3) 🔲 Inform	e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) r No(s)/Mail Date	Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:)-152)			

Art Unit: 1763

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1, 2, 4-6, and 8-12 are rejected under 35 U.S.C. 102(b) as being anticipated by Leusink et al, US Patent 6,302,057 B1.

Leusink et al teaches a CVD apparatus that includes: a processing chamber 10 with an inner space 15; a gas feed member 65 for supplying a gas into the chamber; a metal diffuser 20 partitioning the inner space of the chamber into a first and second partitions having a plurality of holes 21 and includes an "L" shaped extension 54 overlapping a surface 52 of the ceramic insulating frame 120, the ceramic insulating frame 120 disposed in between the chamber side wall and the diffuser or extends to the side wall of the chamber, and located above the surface of the "L" shaped extension and facing the surface of the substrate; and an RF source 24 connected to the diffuser 20 and the pedestal is grounded. (Entire document, specifically Figure 1) The specific substrate processed is an intended use of the apparatus and the apparatus of Leusink et al can inherently process any desired substrate.

Claim Rejections - 35 USC § 103

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

4. Claims 3 and 7 are rejected under 35 U.S.C. 103(a) as being unpatentable over Leusink et al, US Patent 6,302,057, in view of Zhao et al, US Patent 5,558,717.

Leusink et al was discussed above.

Leusink et al differs from the present invention in that Leusink et al does not teach that the diffuser 20 is stainless steel or aluminum, and a baffle plate.

Zhao et al teaches an aluminum diffuser plate 122 and a baffle plate (blocker plate) 124 (Figure 1).

The motivation for making the diffuser of Leusink et al out of aluminum as taught by Zhao et al is to provide a specific metal as required by Leusink et al but only generically described. The motivation for adding a baffle plate to the showerhead of Leusink et al is to more uniformly distribute the gas supplied to the diffuser of Leusink et al as taught by Zhao et al.

Therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to make the diffuser of Leusink et al out of aluminum and add a diffuser as taught by Zhao et al.

Response to Arguments

5. Applicant's arguments filed December 8, 2005 have been fully considered but they are not persuasive.

As the Examiner was preparing the case for allowance, the previously cited art was reviewed. The Examiner reviewed Leusink et al and determined that the previous

definition of "side wall" was too narrowly applied, and if given the broadest reasonable interpretation of the claim language, the term "side wall" includes the top of the chamber (i.e. the top is a side and a wall of the chamber, thus the top is a side wall). Therefore, contrary to Applicant's argument that "that the Leusink reference cited by the Examiner fails to teach or suggest the claimed device. In particular, the Leusink reference fails to teach or suggest that the insulating frame is extends to the side wall of the chamber," Leusink et al extends to a "side wall" of the chamber.

Additionally, the claim language, specifically, the phrase "said insulating frame being disposed on an upper side of the extension of the diffuser and extending to the side wall of the chamber" does not require that the insulating frame contact the "side wall" of the chamber, only that it extends "to" (i.e. in a direction toward) the "side wall". Leusink et al teaches that the insulating frame 22 has an inner diameter and an outer diameter radially outward of the inner diameter. Thus, the insulating of Leusink et al "extends to the side wall of the chamber".

Allowable Subject Matter

- 6. The claims 1-12 would be allowable if claims 1 and 11 were amended to read:
- 1. (currently amended) A chemical vapor deposition apparatus comprising:
 - a chamber having an inner space and top, bottom, and side wall;
 - a susceptor disposed in the chamber and supporting a substrate;
- a diffuser partitioning the inner space of the chamber into first and second partitions and having an extension extended out from a boundary, wherein the extension of the diffuser is exposed to the inner space of the chamber; and

Art Unit: 1763

an insulating frame disposed between the <u>side wall of the</u> chamber and the diffuser, said insulating frame being disposed on an upper side of the extension of the diffuser and extending to <u>and contacting</u> the side wall of the chamber.

11. (currently amended) A chemical vapor deposition apparatus comprising:

a chamber having an inner space and top, bottom, and side wall;

a susceptor disposed in the chamber and supporting a substrate;

a diffuser partitioning the inner space of the chamber into first and second partitions and having an extension of an "L" shape extended out from a boundary, wherein the extension of the diffuser is exposed to the inner space of the chamber; and

an insulating frame disposed between the <u>side wall of the</u> chamber and the diffuser, said insulating frame being disposed on an upper side of the extension of the diffuser and extending to <u>and contacting</u> the side wall of the chamber.

- 7. These amendments are clearly supported in figure 1 which shows that the chamber has a top (lid 20) and a chamber 10 having a bottom and side wall, and that the insulating frame contacts the sidewall of the chamber 10.
- 8. If the claims are amended as indicated above, the amendment will be entered, the search will be updated, and if no further art is found, then the case will be allowed. If art is found, the Examiner will contact the Applicant and try to resolve any problems or issue a Non-Final Office Action.
- 9. If the claims are amended in a different manner with a different scope, the amendment will not be entered, as it will require further search and consideration.

Art Unit: 1763

Conclusion

10. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. The cited art teaches the technological background of the invention.

11. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

12. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jeffrie R. Lund whose telephone number is (571) 272-1437. The examiner can normally be reached on Monday-Thursday (6:30 am-6:00pm).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on (571) 272-1435. The fax phone number for the organization where this application or proceeding is assigned is 571-

Art Unit: 1763

273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jeffrie R. Lund Primary Examiner Art Unit 1763

JRL 10/12/06